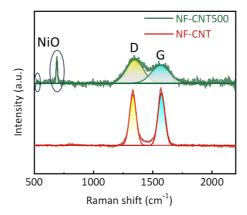
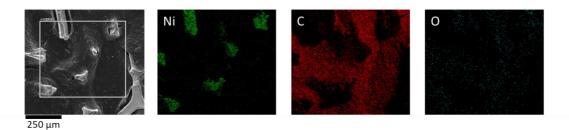
Supplementary Material

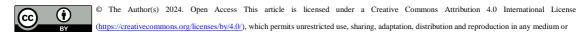
A hierarchical host microstructure enables regulated inner Li deposition for stable Li metal electrodes



Supplementary Figure 1. Raman spectrum of NF-CNT and NF-CNT500

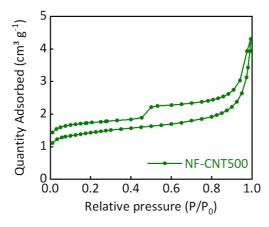


Supplementary Figure 2. SEM and EDS images of NF-CNT500.



format, for any purpose, even commercially, as long as you give appropriate credit to the original author(s) and the source, provide a link to the Creative Commons license, and indicate if changes were made.

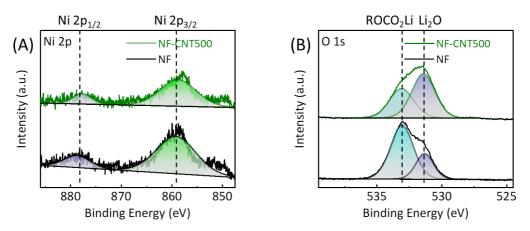




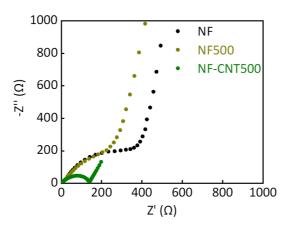
Supplementary Figure 3. BET measurement of NF-CNT500.



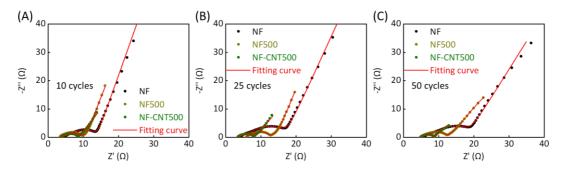
Supplementary Figure 4. Digital photos of molten Li infusion in NF-CNT500.



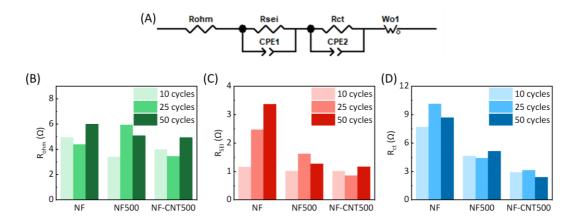
Supplementary Figure 5. (A) Ni 2p and (B) O 1s XPS spectra of initially cycled NF and NF-CNT500.



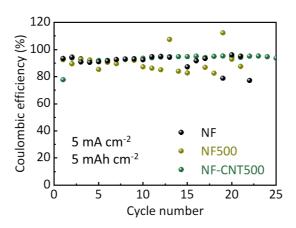
Supplementary Figure 6. EIS spectrum of Li || Ni half cells using NF, NF500 and NF-CNT500 before cycling.



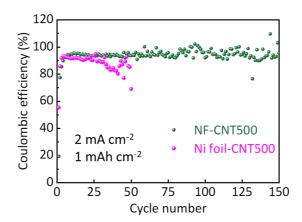
Supplementary Figure 7. EIS spectra of Li || Ni half cells using NF, NF500 and NF-CNT500 after (A) 10, (B) 25 and (C) 50 cycles at 1 mA cm⁻² - 1 mAh cm⁻².



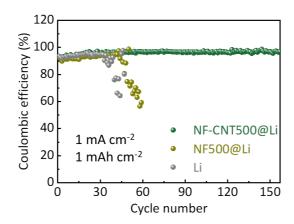
Supplementary Figure 8. (A) Equivalent circuit diagram used for EIS spectral fitting. (B) R_{ohm} , (C) R_{SEI} and (D) R_{ct} obtained by fitting the EIS spectra of Li || Ni half cells upon cycling at 1 mA cm⁻² - 1 mAh cm⁻².



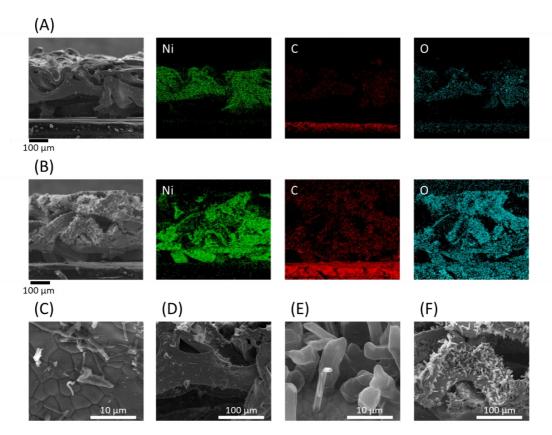
Supplementary Figure 9. Cycling CE of Li plating/stripping on the investigated hosts at 5 mA cm⁻² - 5 mAh cm⁻².



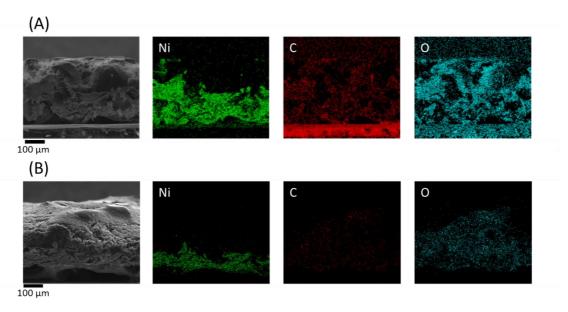
Supplementary Figure 10. Cycling CE of Li plating/stripping on NF-CNT500 and Ni foil-CNT500 at 2 mA cm^{-2} - 1 mAh cm^{-2} .



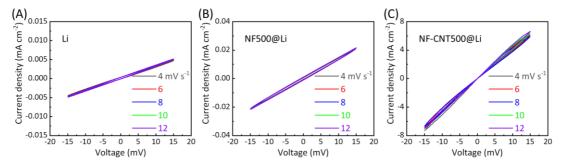
Supplementary Figure 11. Cycling CE of Li \parallel Cu half cells using Li, NF500@Li and NF-CNT500@Li at 1 mA cm⁻² - 1 mAh cm⁻².



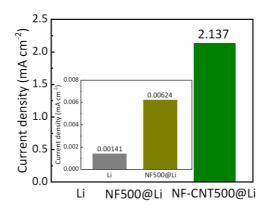
Supplementary Figure 12. Cross-section SEM and EDS images of (A) NF and (B) NF-CNT500 at a Li plating capacity of 1 mAh cm⁻². Amplified cross-section SEM images of (C, D) NF and (E, F) NF-CNT500 at a Li plating capacity of 1 mAh cm⁻².



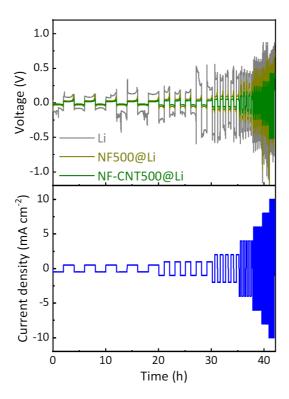
Supplementary Figure 13. Cross-section SEM and EDS images of (A) NF and (B) NF-CNT500 at a Li plating capacity of 4 mAh cm⁻².



Supplementary Figure 14. CV curves of symmetrical cells using (A) Li, (B) NF500@Li and (C) NF-CNT500@Li electrodes, recorded in the voltage window of ±15 mV at different scanning rates.



Supplementary Figure 15. Exchange current density of the investigated symmetrical cells.



Supplementary Figure 16. Voltage profile of symmetrical cells during rate ability test.